

L Number	Hits	Search Text	DB	Time stamp
1	1018	(aluminum adj nitride) adj (substrate or layer)	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 12:53
3	3	((aluminum adj nitride) adj (substrate or layer)) and thickness and mil) and capacitor	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 13:33
4	1	(aluminum adj nitride adj substrate) same thickness same mil	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 12:58
5	641	(aluminum adj nitride adj substrate)	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 12:58
6	24	((aluminum adj nitride adj substrate)) and thickness and mil	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 12:58
7	2	((aluminum adj nitride adj substrate)) and thickness and mil) and capacitor	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 12:59
8	38	((aluminum adj nitride adj substrate)) and capacitor	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 13:30
9	11	("2585700" "3247573" "3753816" "3947956" "4176443" "4546065" "4591537" "4649070" "4659611" "4770953" "4882839").PN.	USPAT	2003/04/03 13:17
12	5	5184399.URPN.	USPAT	2003/04/03 13:18
13	95	257/700.ccls. and (aluminum adj nitride)	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 13:30
14	21	(257/700.ccls. and (aluminum adj nitride)) and capacitor	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 13:33
15	534	((aluminum adj nitride) adj (substrate or layer)) and thickness	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 13:33
16	3	((aluminum adj nitride) adj (substrate or layer)) and thickness) and (decoupling adj capacitor)	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 14:24
17	12	("5123613" or ("5377072") or ("5791139") or ("6049973") or ("6137275") or ("6147678")).PN.	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 13:36
18	13	("3268744" "4167018" "4914546" "4929989" "5049979" "5055905" "5083184" "5095402" "5140496" "5187637" "5281846" "5311057" "5313693").PN.	USPAT	2003/04/03 13:38
21	1	5377072.URPN.	USPAT	2003/04/03 13:40
2	30	((aluminum adj nitride) adj (substrate or layer)) and thickness and mil	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 13:44
22	0	361/763.ccls. and ((aluminum adj nitride) adj (substrate or layer))	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 13:45

23	4	361/763.ccls. and (aluminum adj nitride)	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 13:50
24	3257	decoupling adj capacitor	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 13:48
25	6	((aluminum adj nitride) adj (substrate or layer)) and (decoupling adj capacitor)	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 13:48
26	41	(decoupling adj capacitor) and (aluminum adj nitride)	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 14:22
27	29	((decoupling adj capacitor) and (aluminum adj nitride)) and thickness	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 14:23
28	26947	ceramic adj substrate	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 13:55
29	1227	(ceramic adj substrate) and (aluminum adj nitride)	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 15:03
30	882	((ceramic adj substrate) and (aluminum adj nitride)) and thickness	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 14:23
32	1	((((ceramic adj substrate) and (aluminum adj nitride)) and (thickness near mil)) and (decoupling adj capacitor)	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 15:01
33	18	((((ceramic adj substrate) and (aluminum adj nitride)) and thickness) and (decoupling adj capacitor)	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 14:24
34	40	5272590.URPN.	USPAT	2003/04/03 14:29
31	18	((ceramic adj substrate) and (aluminum adj nitride)) and (thickness near mil)	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 14:30
36	1	((decoupling adj capacitor) adj (apparatus or assembly)) and (aluminum adj nitride)	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 15:05
37	1	((decoupling adj capacitor) adj (apparatus or assembly)) and (ceramic adj substrate)	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 15:07
38	13	4734819.URPN.	USPAT	2003/04/03 15:06
39	2	("6441483").PN.	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 15:07
40	20	("4996587" "5444296" "5652463" "5674785" "5808878" "5898224" "5952611" "5973403" "5994166" "5994773" "6005778" "6013948" "6020629" "6051878" "6081023" "6087717" "6181002" "6262488" "6265771" "6316727" "2001/0015485").PN.	USPAT	2003/04/03 15:07

35	26	(decoupling adj capacitor) adj (apparatus or assembly)	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 15:15
41	2	("5184399").PN.	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 15:12
42	11	("2585700" "3247573" "3753816" "3947956" "4176443" "4546065" "4591537" "4649070" "4659611" "4770953" "4882839").PN.	USPAT	2003/04/03 15:12
45	5	5184399.URPN.	USPAT	2003/04/03 15:14
46	26	(decoupling adj capacitor) adj (apparatus or assembly or assemblies)	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 15:24
47	1	((decoupling adj capacitor) adj (apparatus or assembly)) and (ceramic adj substrate)	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 15:25
48	53	361/306.2.ccls. and substrate	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 15:18
49	6	(361/306.2.ccls. and substrate) and (ALN or (aluminum adj nitride))	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 15:19
50	6	(361/306.2.ccls. and substrate) and (AlN or (aluminum adj nitride))	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 15:25
51	3257	(decoupling adj capacitor)	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 15:24
52	96	((decoupling adj capacitor)) and (ceramic adj substrate)	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 15:25
53	23	((decoupling adj capacitor)) and (ceramic adj substrate)) and (AlN or (aluminum adj nitride))	USPAT; EPO; JPO; DERWENT; USOCR	2003/04/03 15:25